

Report Title

New Approaches for Characterization of Heterogeneous Material Integration Quality

ABSTRACT

2013 North American Molecular Beam Epitaxy Conference -Post-Conference Workshops,, Banff, Alberta, Canada
(October 5-11 2013)

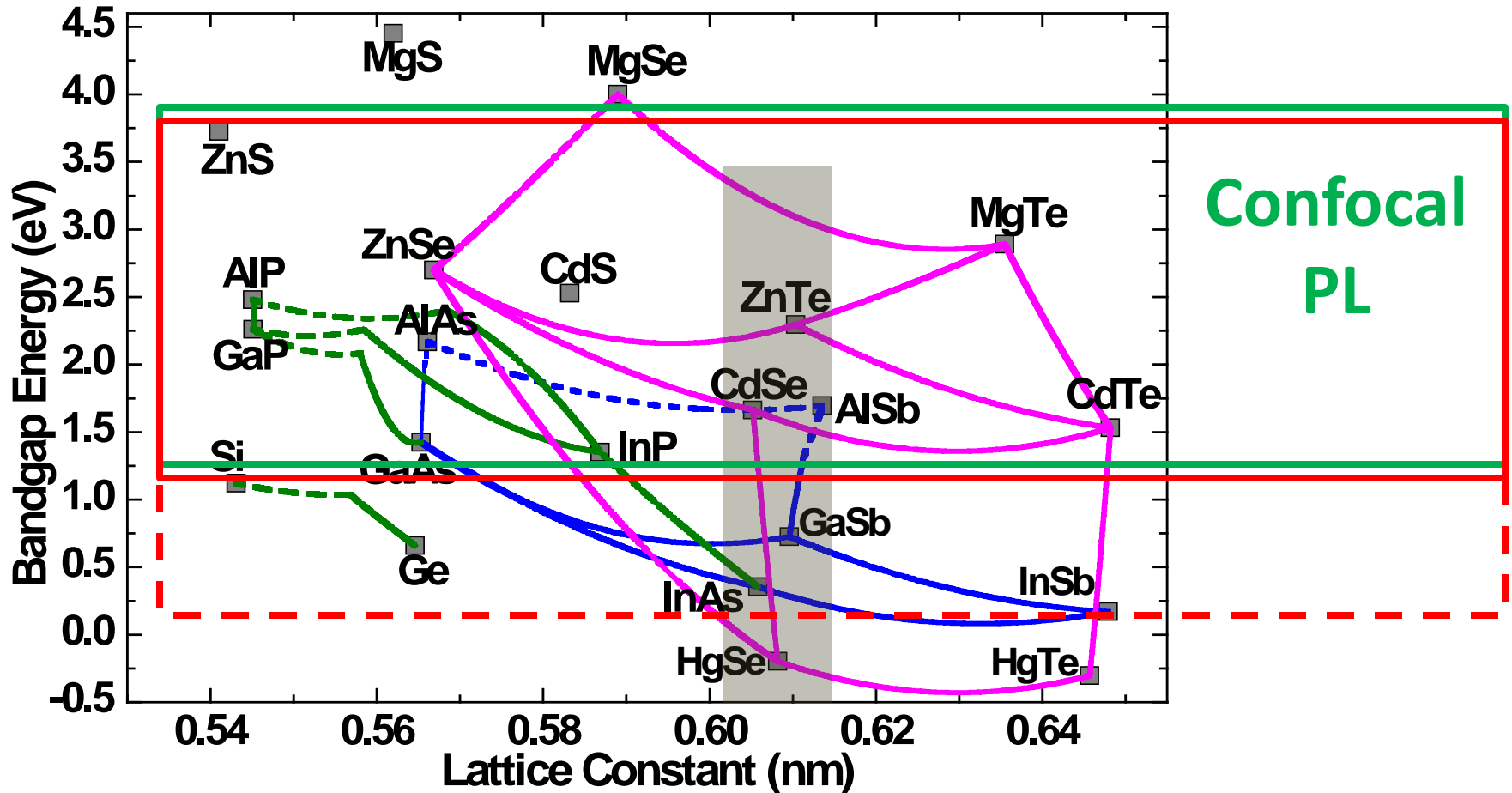
New Approaches for Characterization of Heterogeneous Material Integration Quality

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Texas State University – San Marcos

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Cathodoluminescence

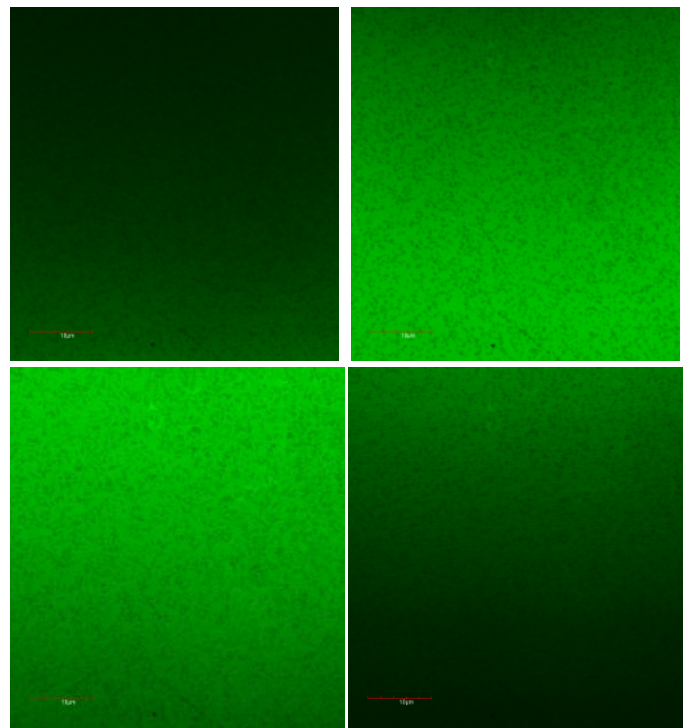
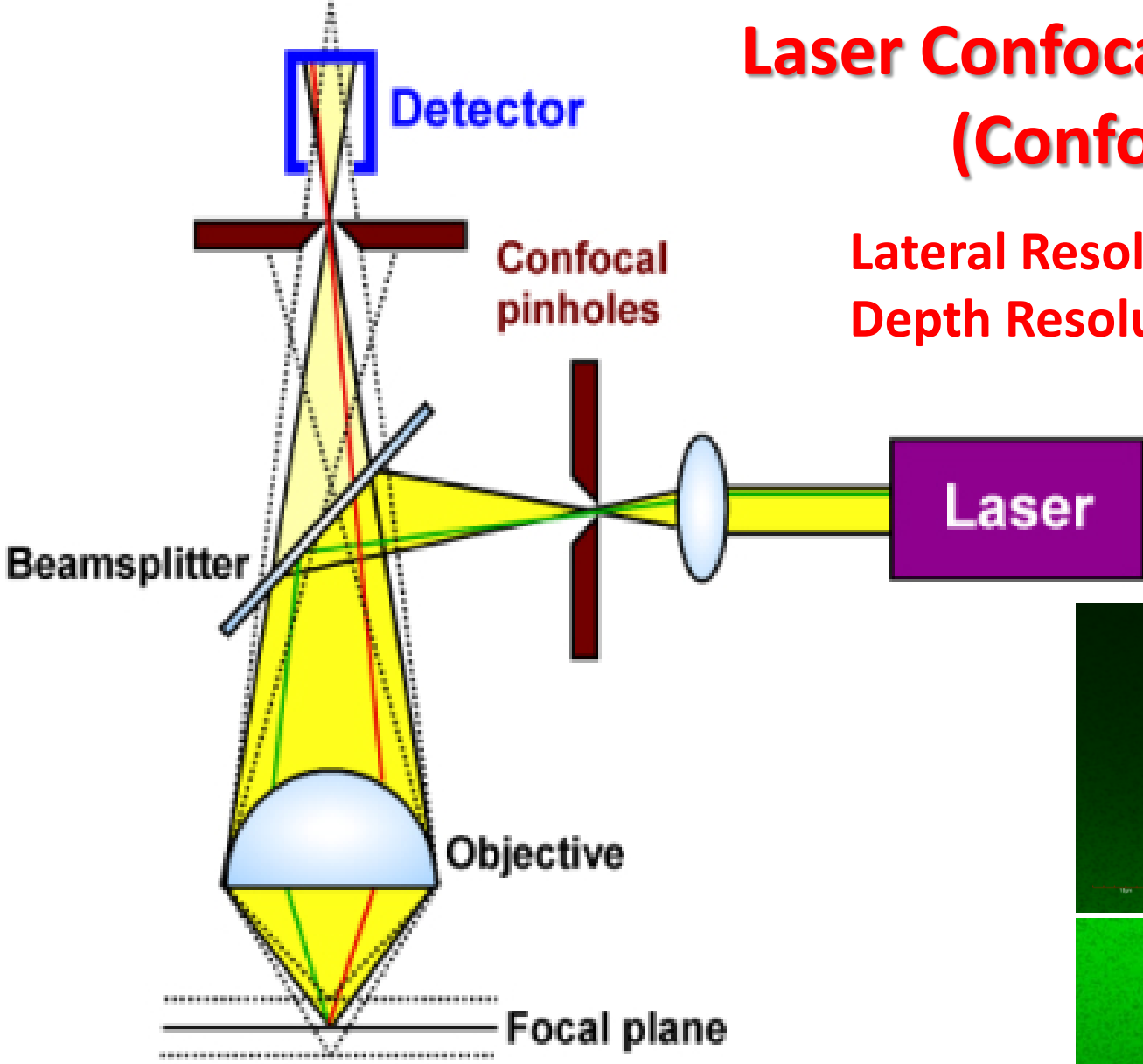


The 6.1 Å Alloy System can be used to grow a host of nearly lattice matched materials (III-V and II-VI), from infrared to UV

Laser Confocal Microscopy (Confocal PL)

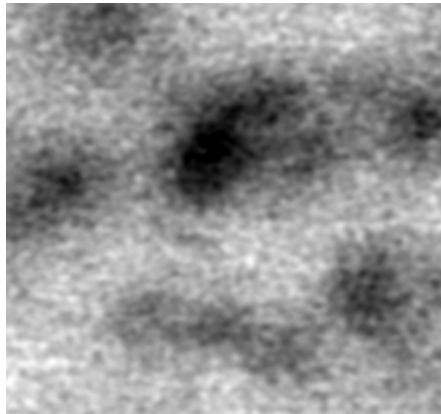
Lateral Resolution $0.25 \mu\text{m}$
Depth Resolution $0.25\text{-}0.5 \mu\text{m}$

$0.25 \mu\text{m}$ Steps on
 $0.25 \mu\text{m}$ Thick ZnTe

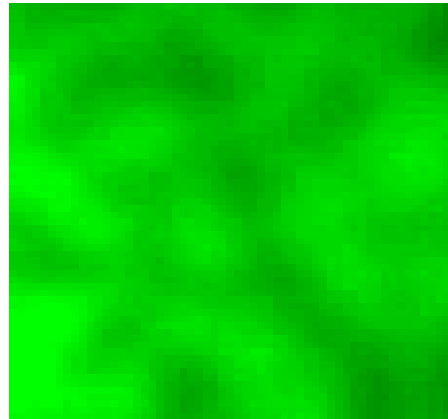


Confocal PL provides highest contrast

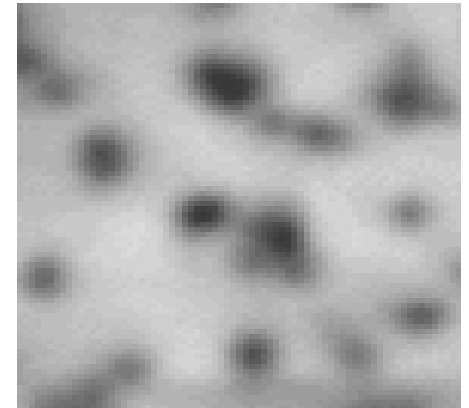
Cathodoluminescence



Imaging
Photoluminescence



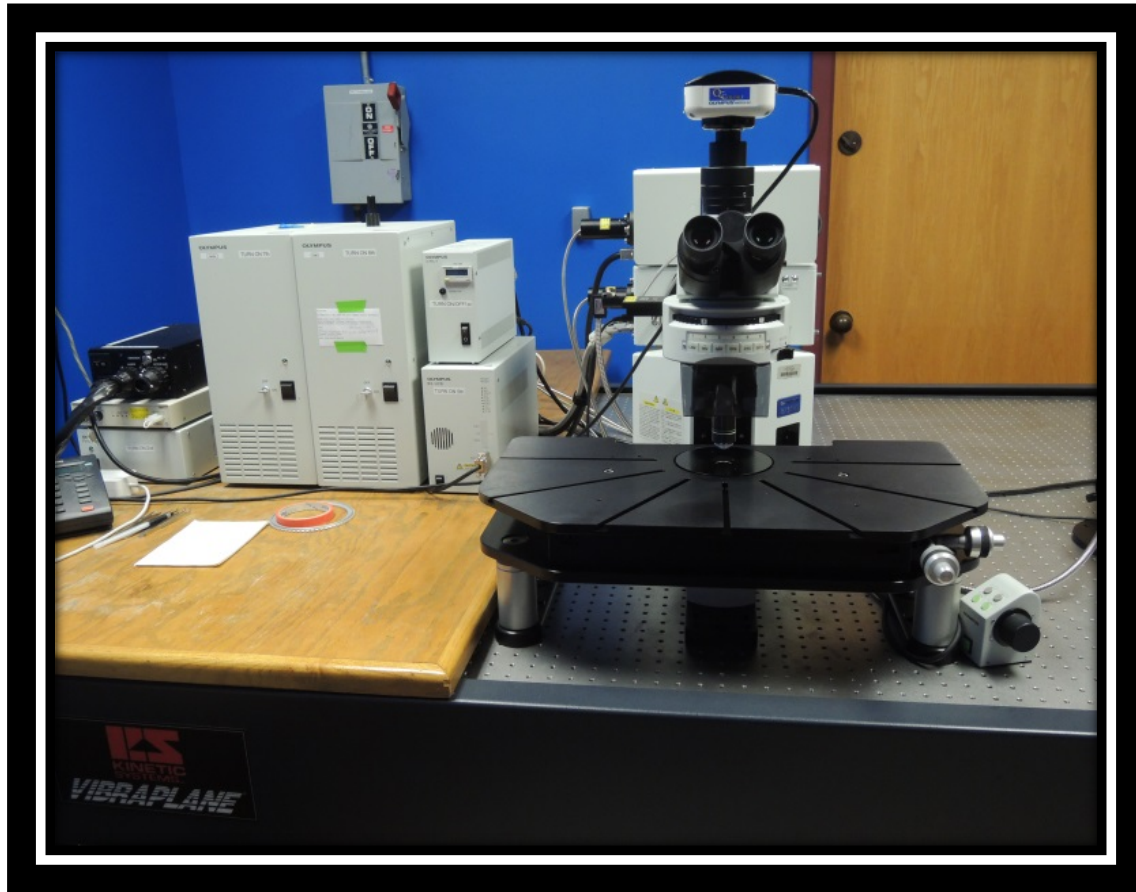
Confocal
Photoluminescence



5 μm

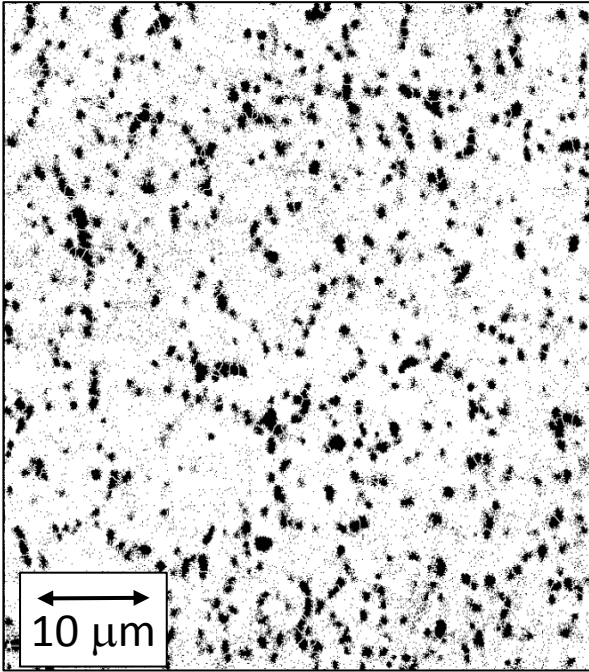
1000 nm ZnTe

Olympus FV1000 Laser Scanning Confocal Microscope



- high-resolution confocal observation of fixed and living cells,
- point-detection, variable bandwidth filtering, 3-D imaging, and time experiments.
- multi-line Argon lasers: 515, 488, and 458, and Diode lasers 405, 559, and 635.
- brightfield or DIC imaging,
- motorized upright microscope.

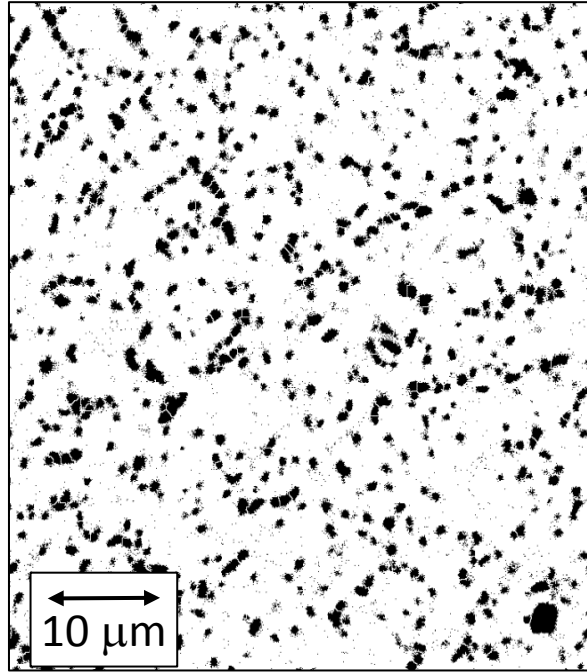
Effect of Lattice Matching



$\sim 3 \times 10^7 \text{ cm}^{-2}$

2- μm thick

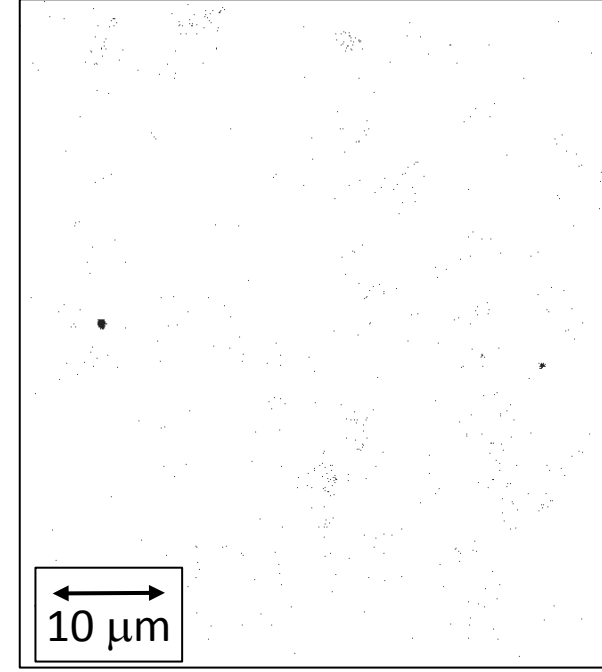
ZnTe/GaSb (211)B



$\sim 3 \times 10^7 \text{ cm}^{-2}$

2- μm thick

ZnTe/GaSb (100)

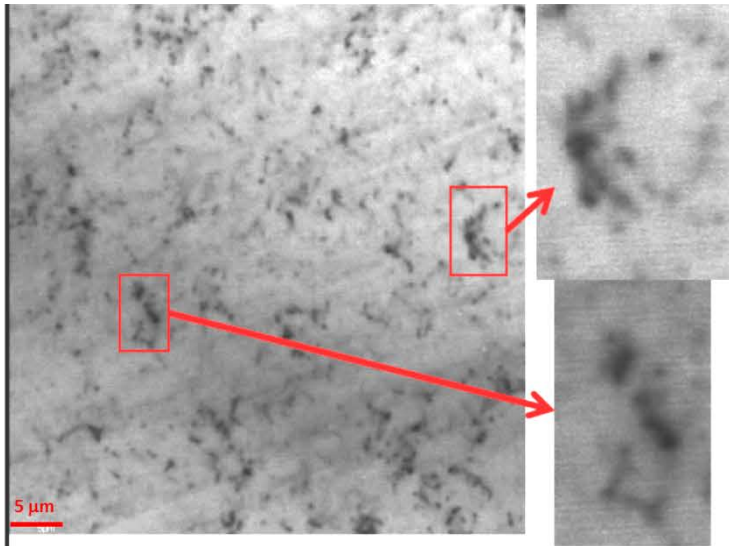


$\sim 7 \times 10^4 \text{ cm}^{-2}$

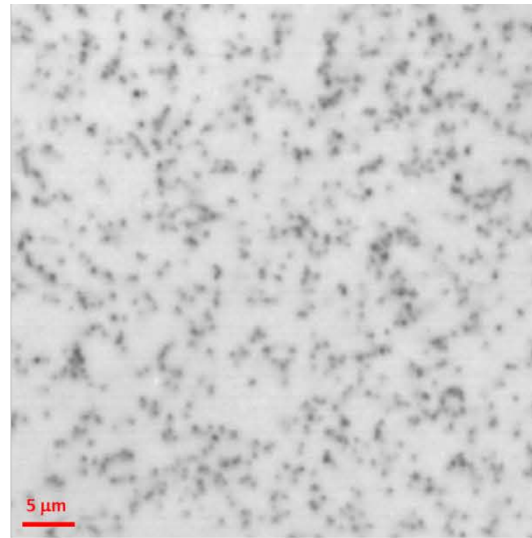
1.2- μm thick

ZnTe_{0.99}Se_{0.01}/
GaSb (211)B

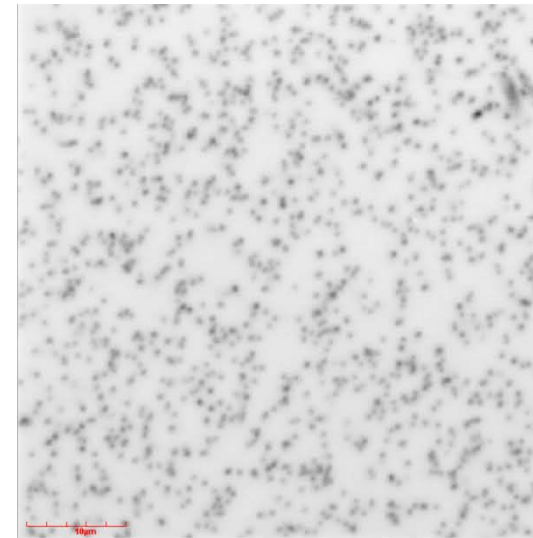
Evaluation of II-VI Growth on Alternative Substrates



c-PL micrograph of ZnTe/Si suggestive of dislocation clustering with a measured “dislocation” density of $2 \times 10^7 \text{cm}^{-2}$

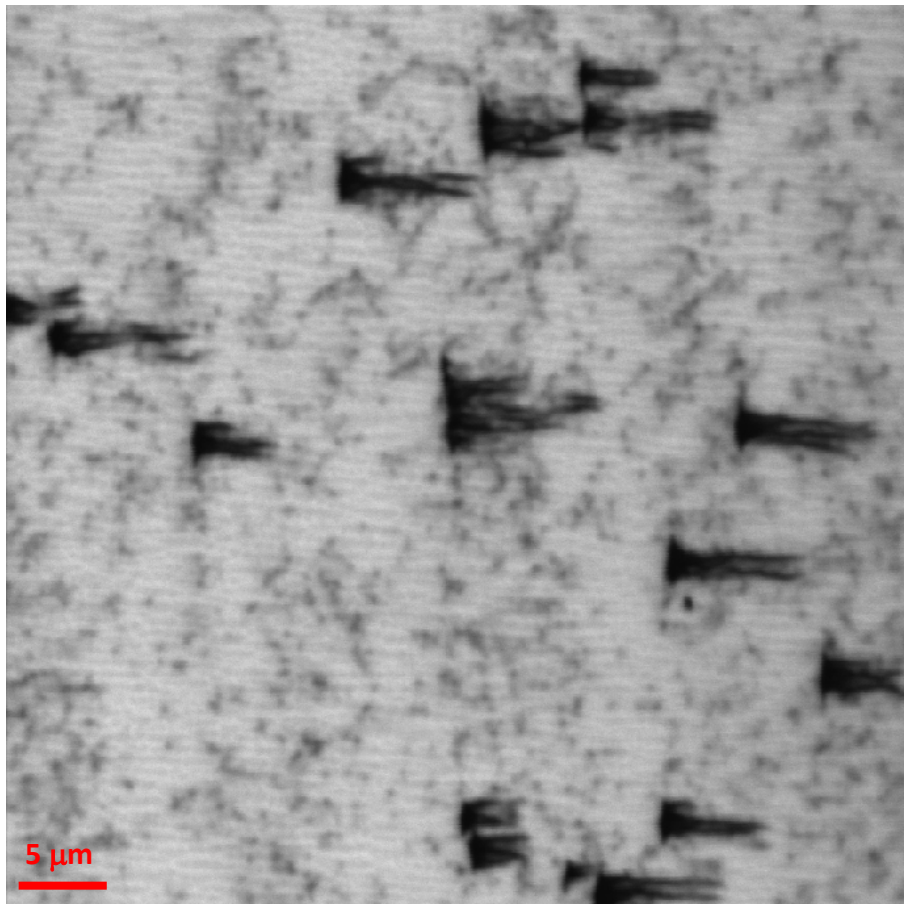


c-PL micrograph of CdTe/Si less suggestive of dislocation clustering with a measured “dislocation” density of $2 \times 10^7 \text{cm}^{-2}$

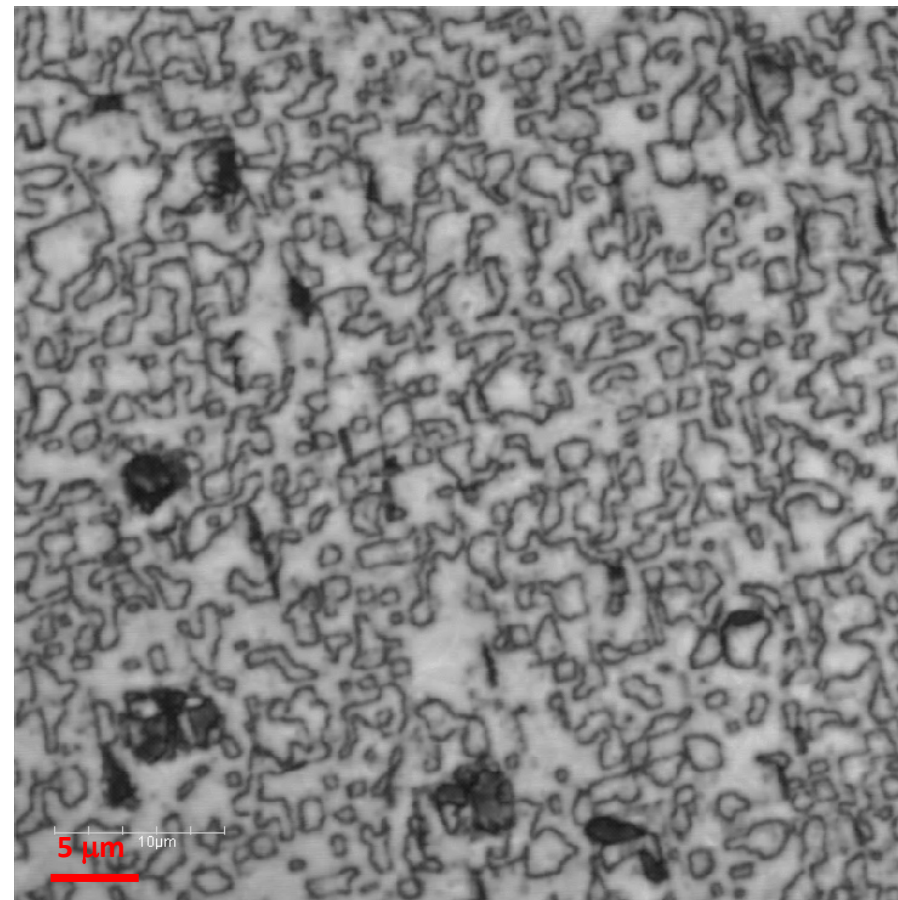


c-PL micrograph of (211)B CdTe/GaAs showing a “non-clustered” defect distribution with a density of $2 \times 10^7 \text{cm}^{-2}$.

Twin-related Defects



c-PL micrograph of (211)B ZnTe/Si showing twinning occurring during MBE growth



c-PL micrograph of (111)B CdTe/CdTe showing twinning occurring during MBE growth

Cathodoluminescence

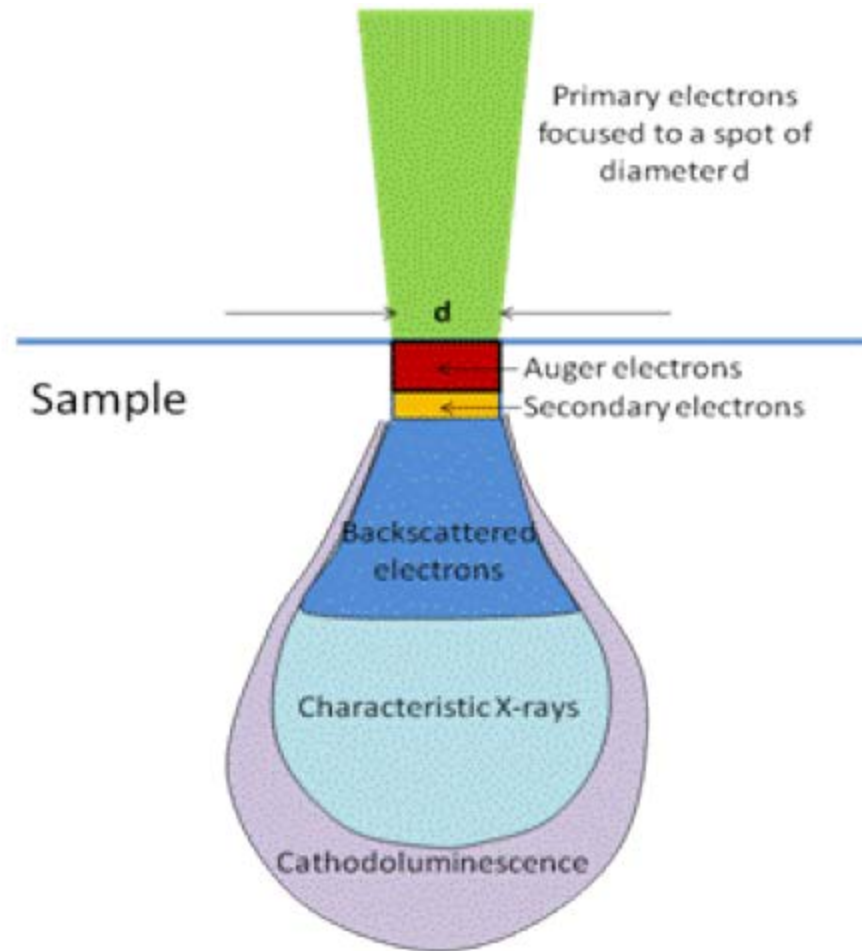
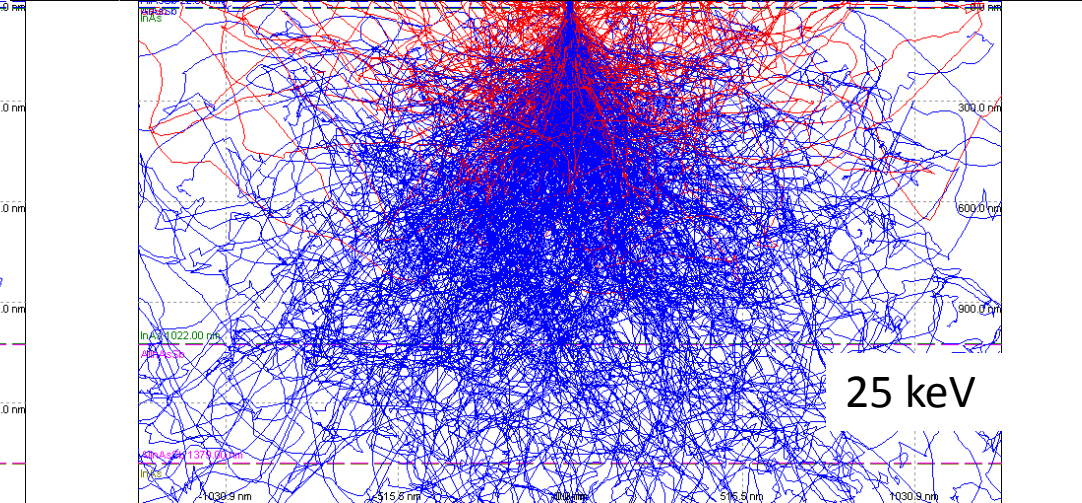
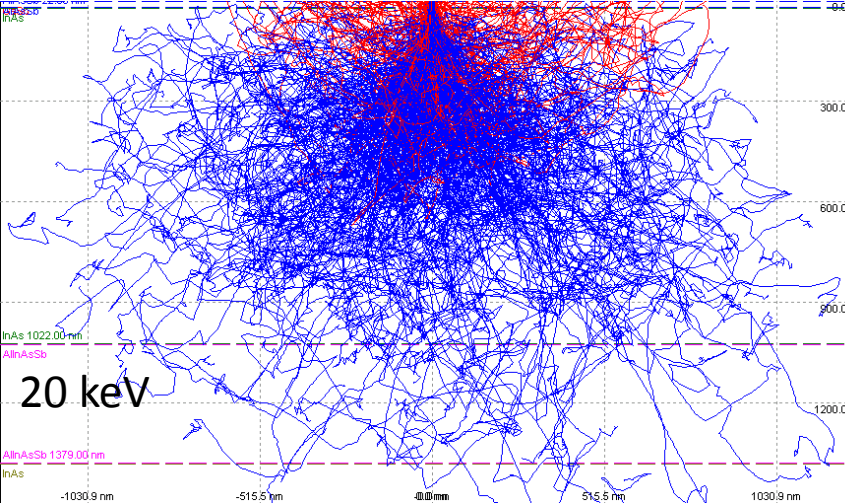
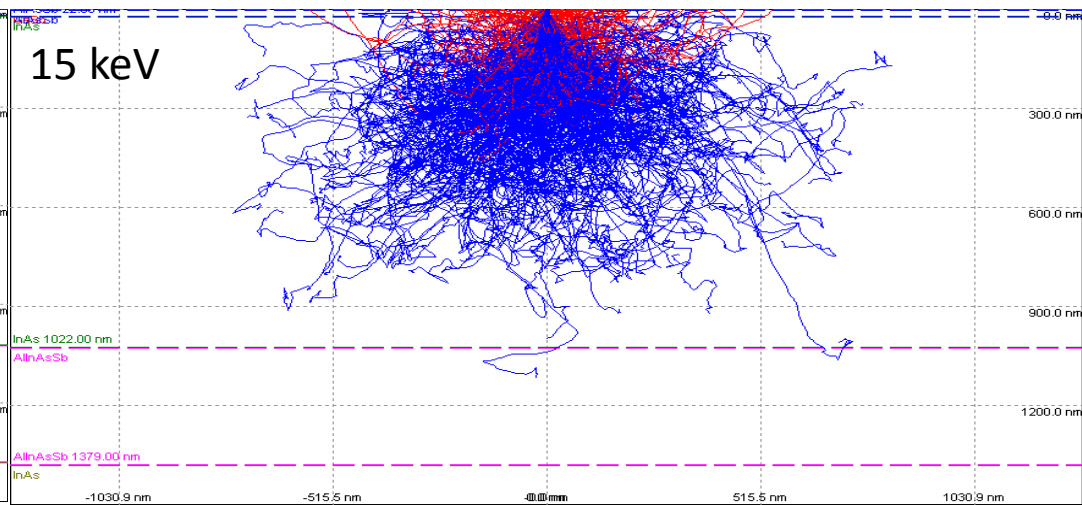
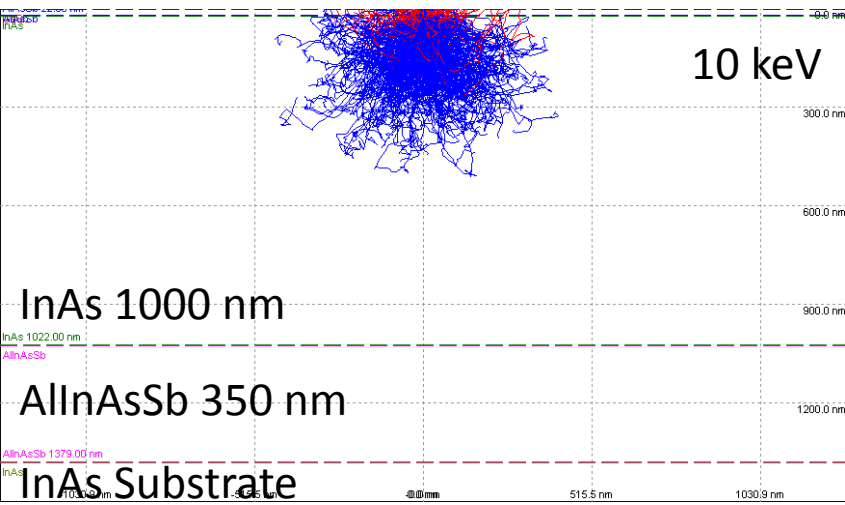
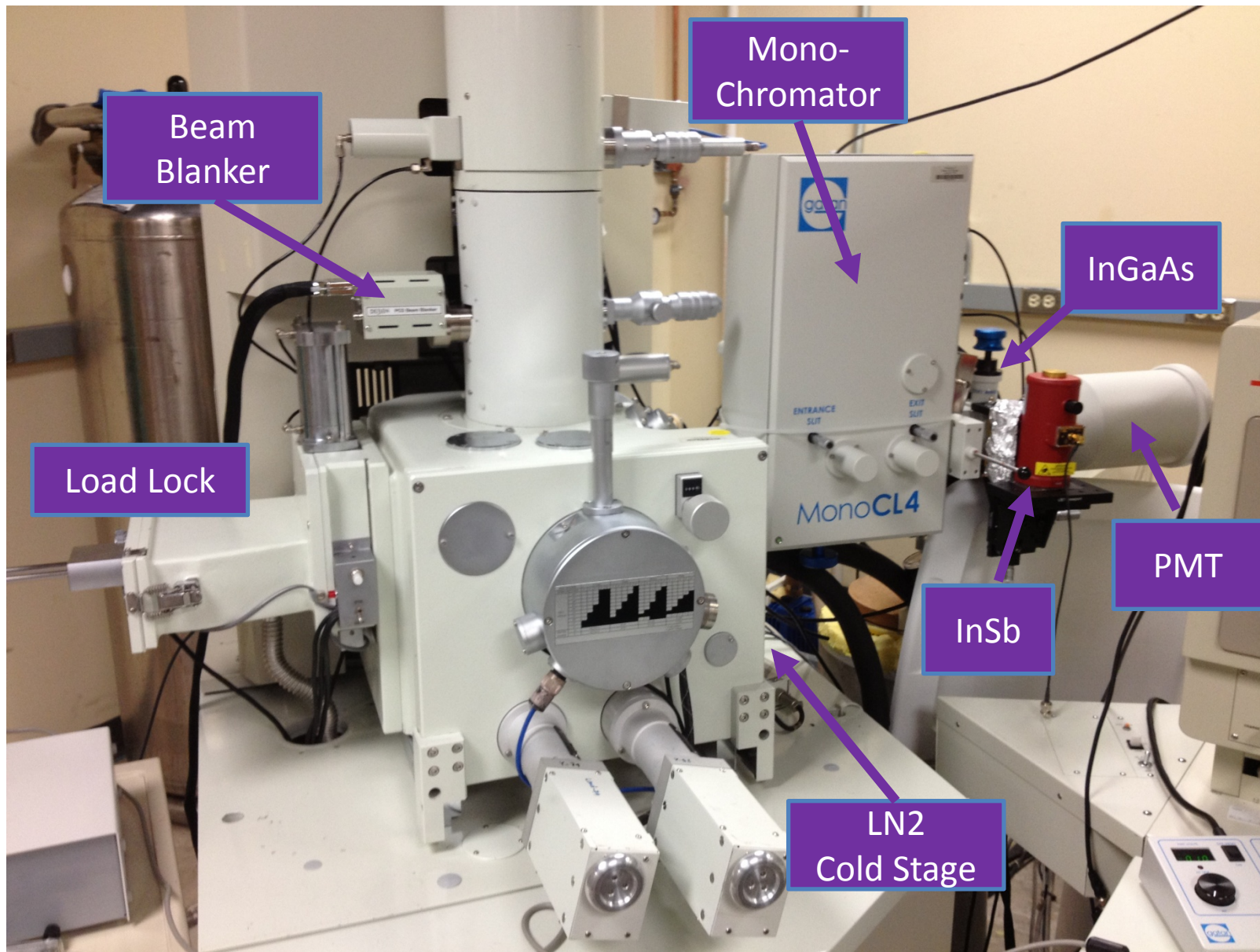
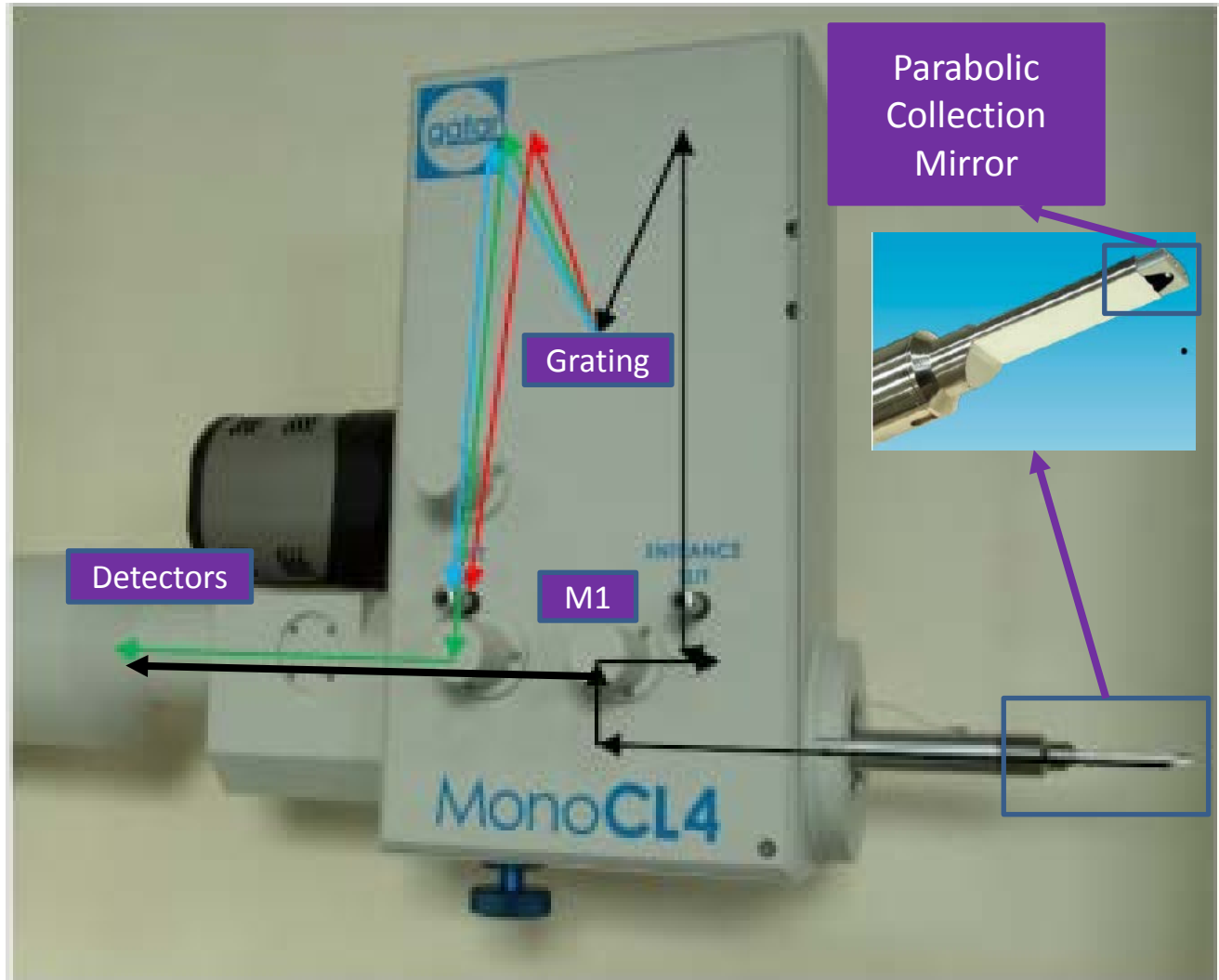


Figure 23 - the generation (interaction) volume and the location of some of the signals generated within it



Simulation of Electron Penetration





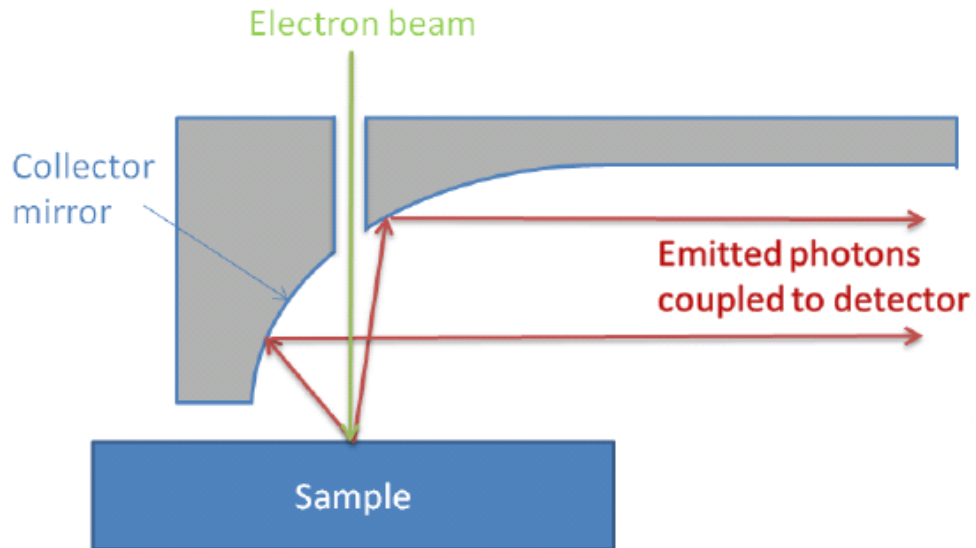
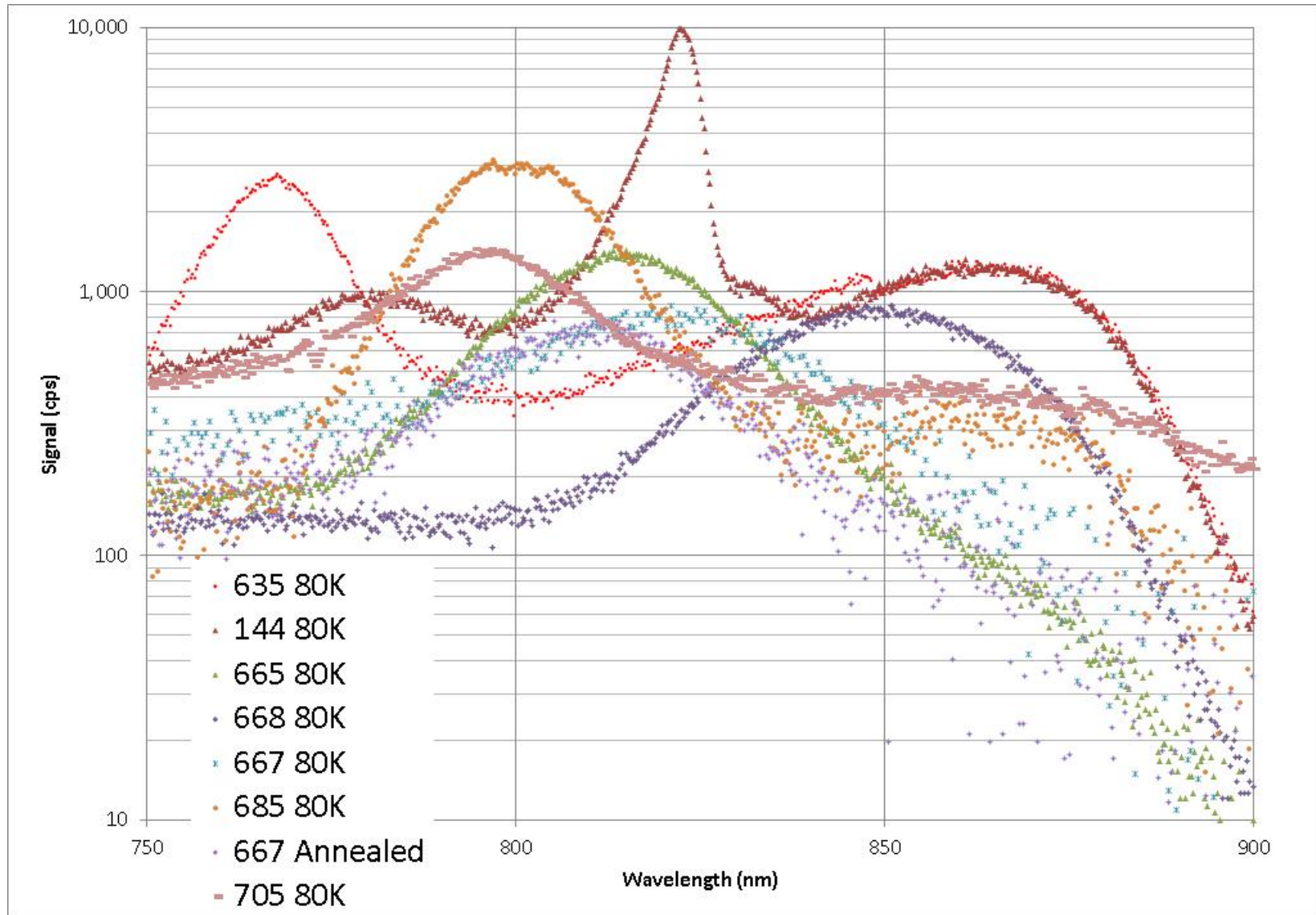


Figure 24 - schematic representation of CL setup with a parabolic mirror used to couple photons efficiently to a detector

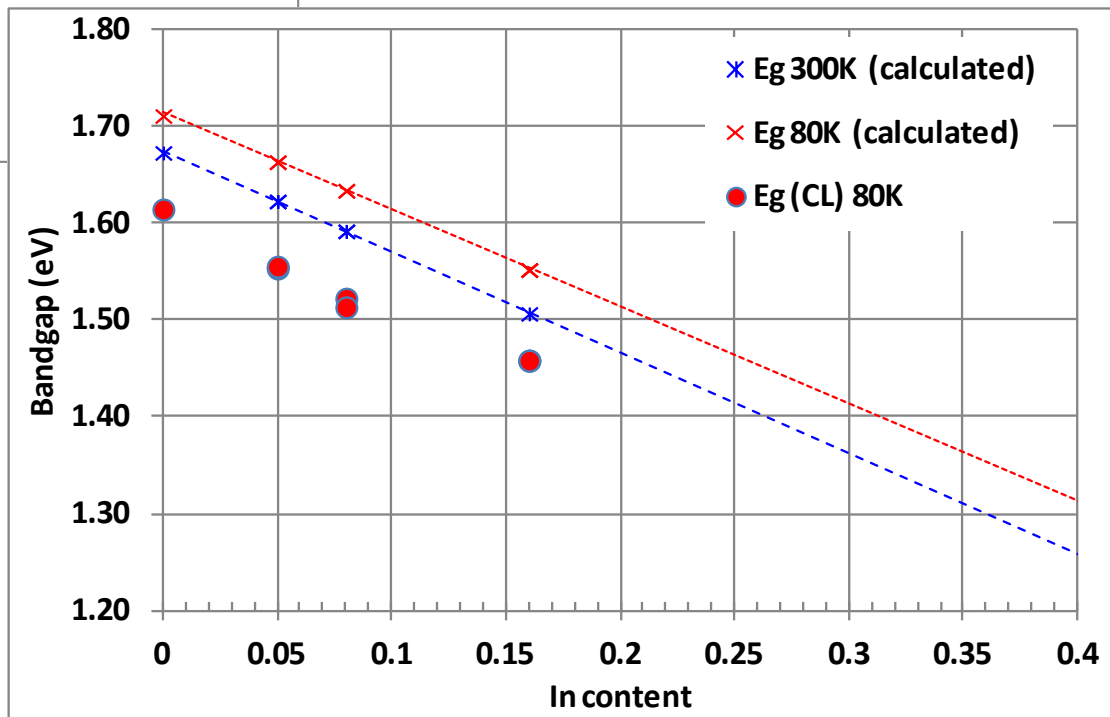
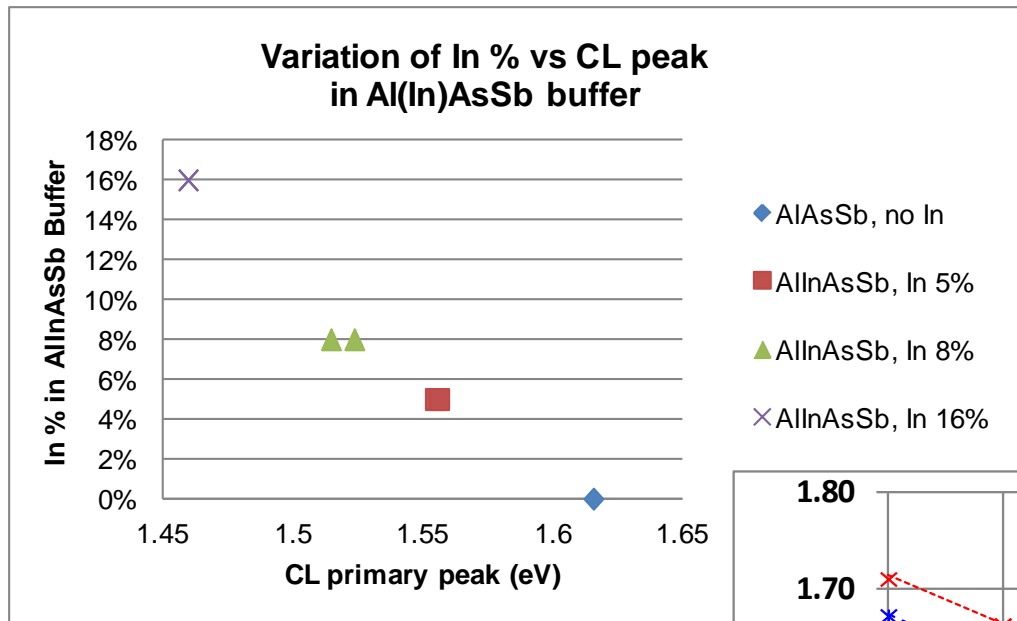
Very High Collection Efficiency

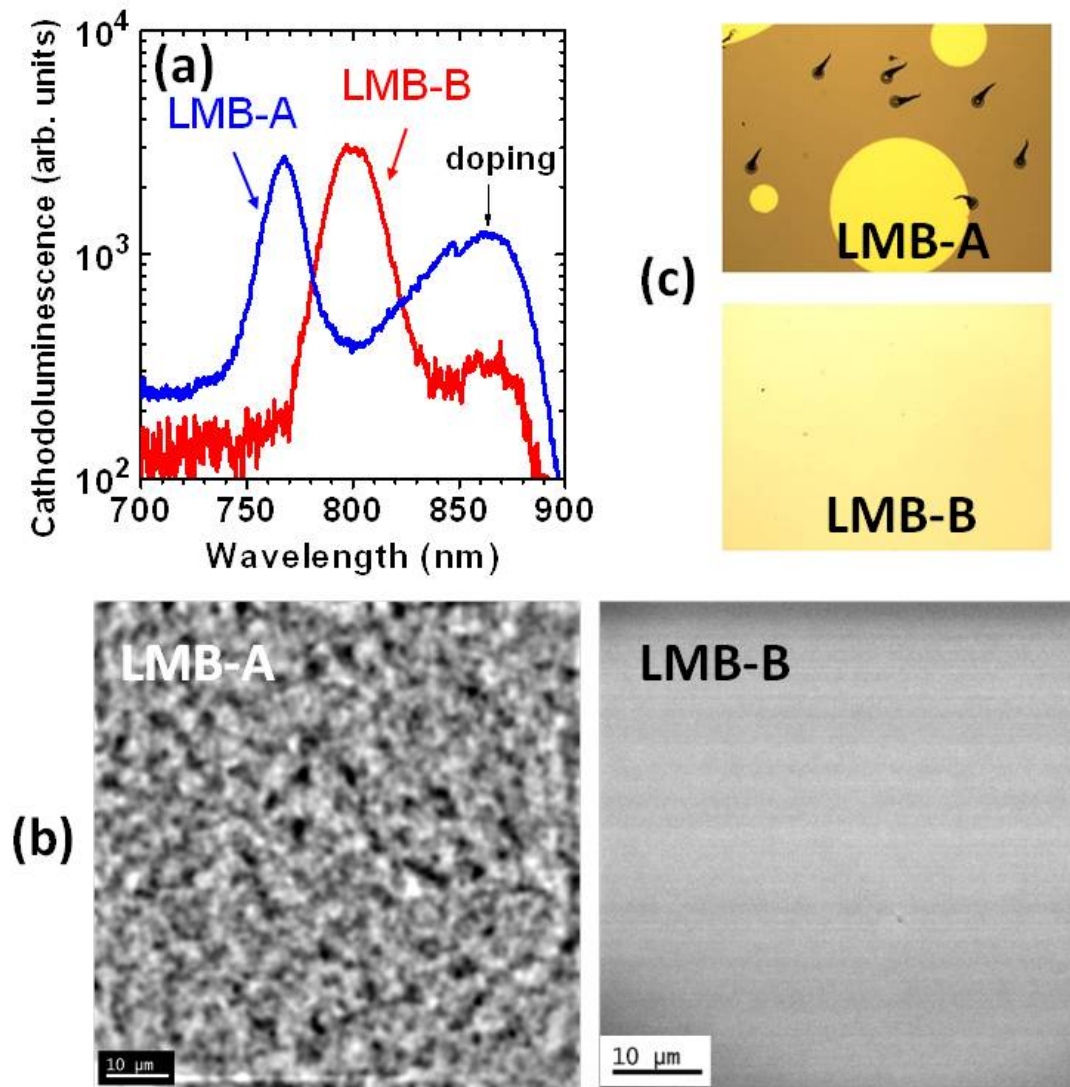
> 75%

Indirect gap layer - InAlAsSb



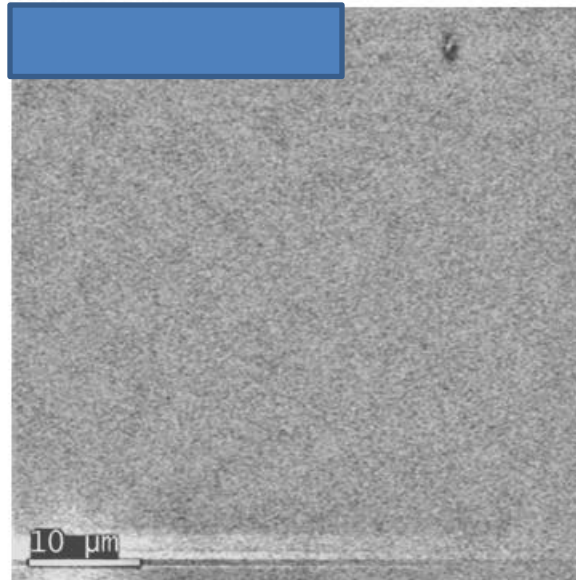
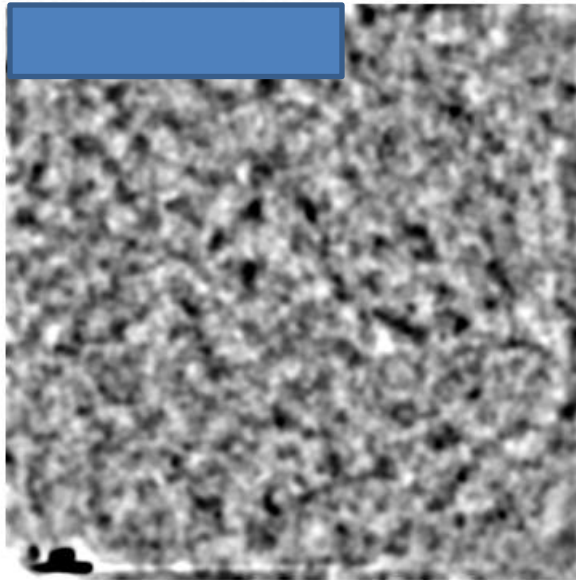
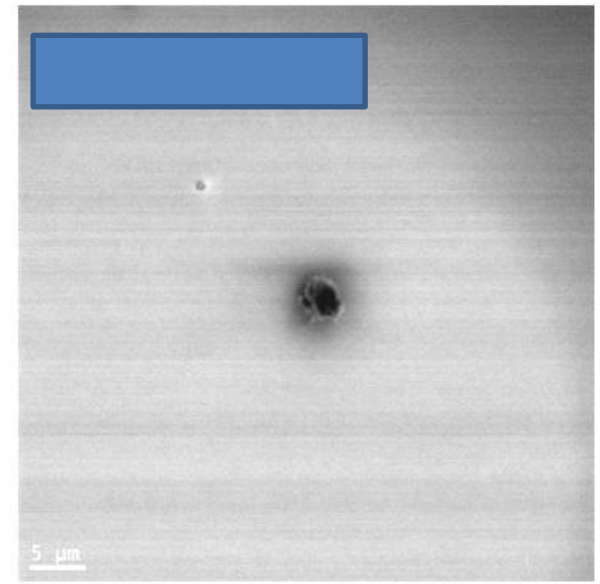
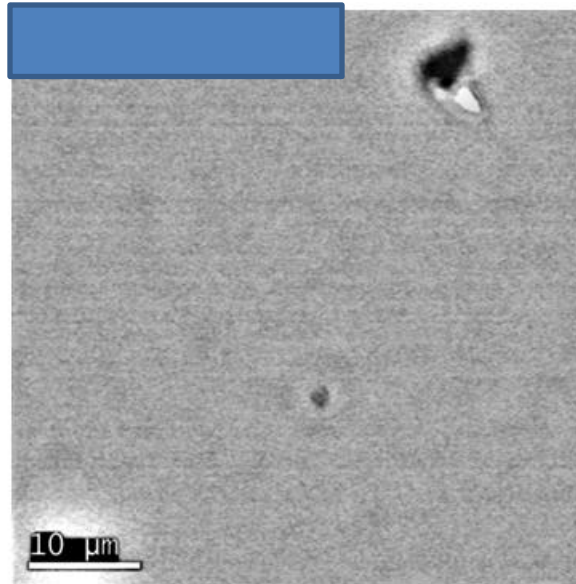
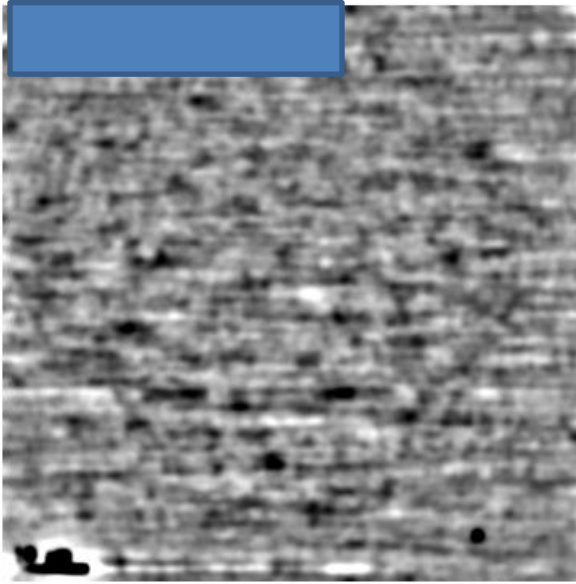
Estimated In% and Calculated E_g in AlInAsSb vs E_g from CL Primary Peak





(a) CL spectra, (b) panchromatic CL images, and (c) optical images of the InAs surface after exposure to diluted HF of the LMB-A and LMB-B structures of Fig. 4. Defectivity of LMB-A is only revealed in CL images (b) and manifested by attack of defect sites (c).

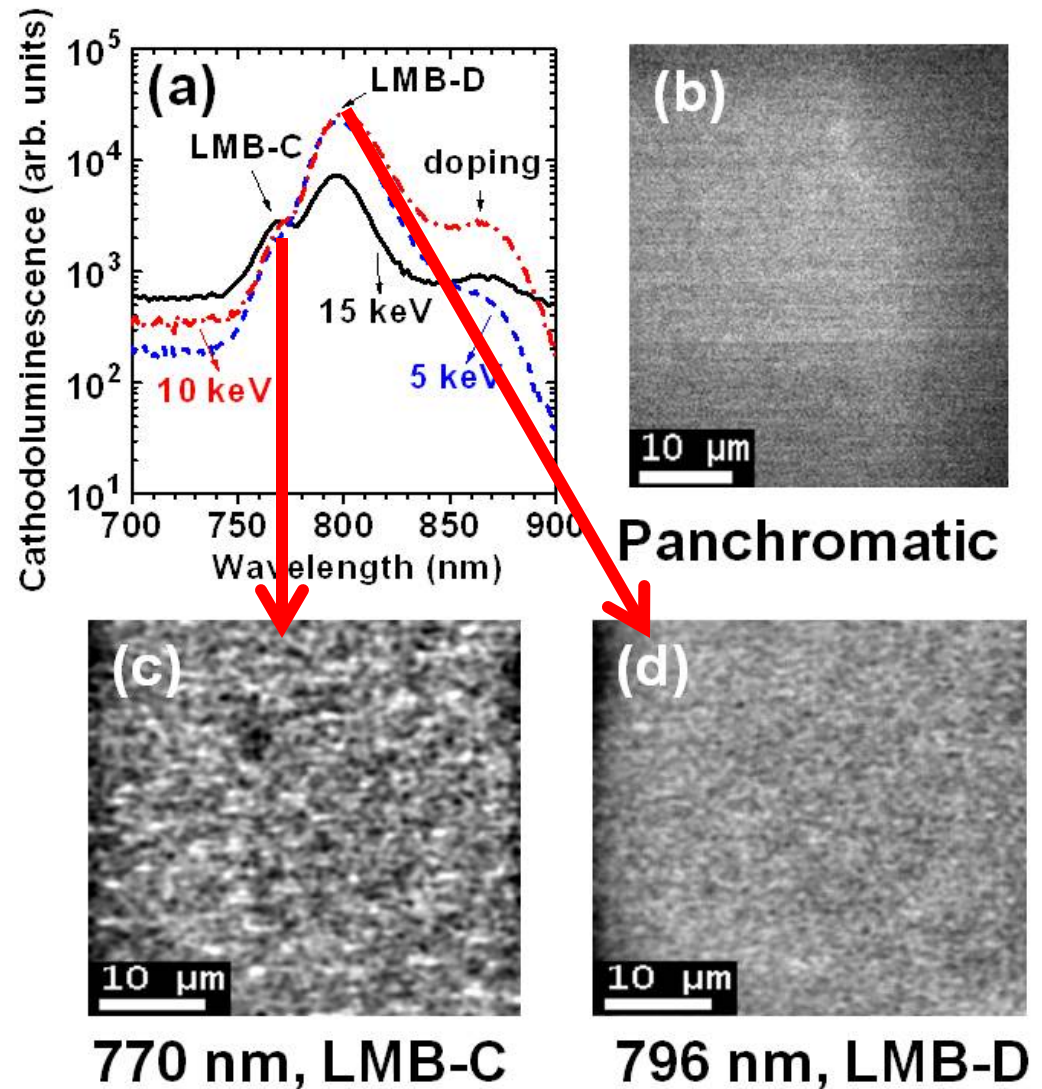
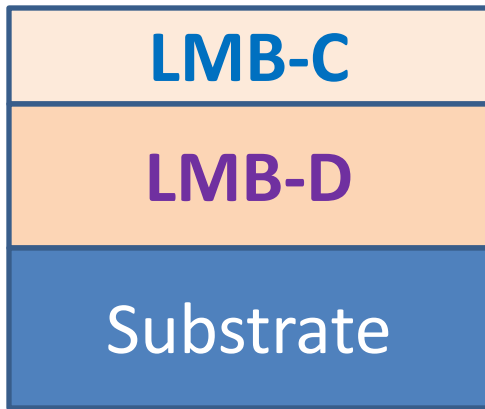
CL Image Comparison AllnAsSb Different growth conditions (80K)



Defect density $\sim 10^9 \text{ cm}^{-2}$

Defect density $\sim 10^5 \text{ cm}^{-2}$

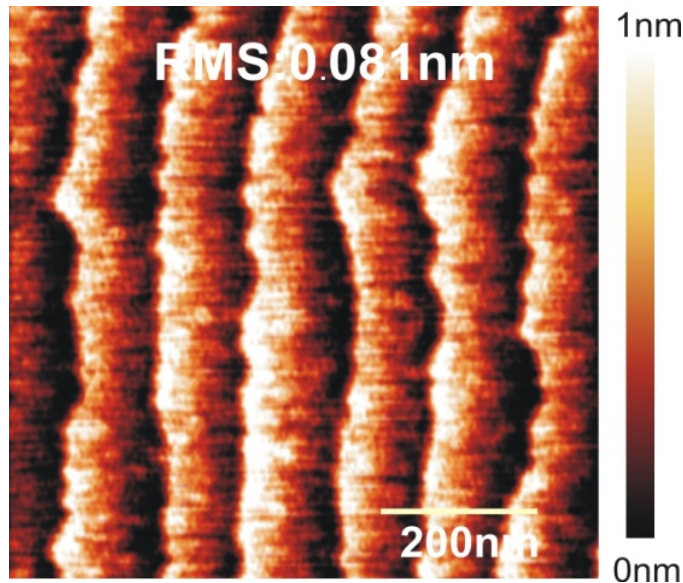
No obvious non radiative defects observed



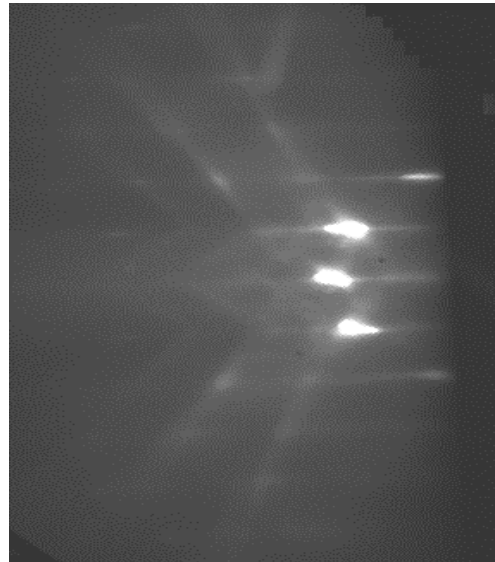
(a) CL spectra, (b) panchromatic CL image, (c) monochromatic CL image of LMB-C and (d) monochromatic CL image of LMB-D. In panchromatic image, the defectivity of LMB-C is not visible whereas monochromatic images show defectivity of LMB-C and defect free LMB-D.

MBE grown GaSb on GaAs (100)

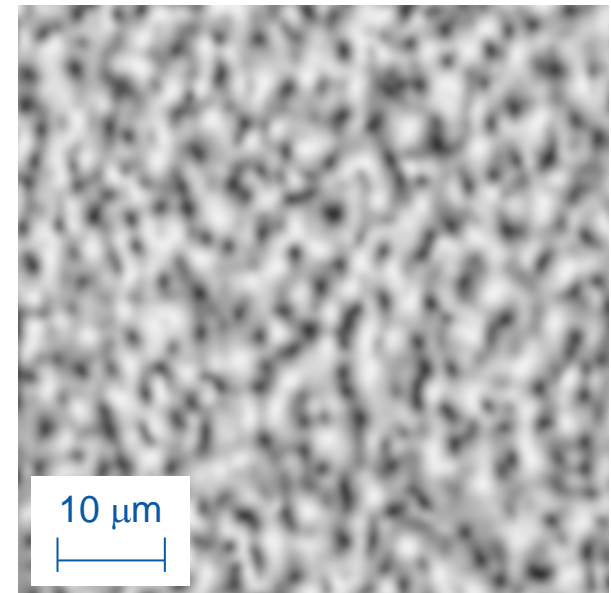
HRXRD FWHM of about 150 arcsecond,



in-situ AFM



RHEED

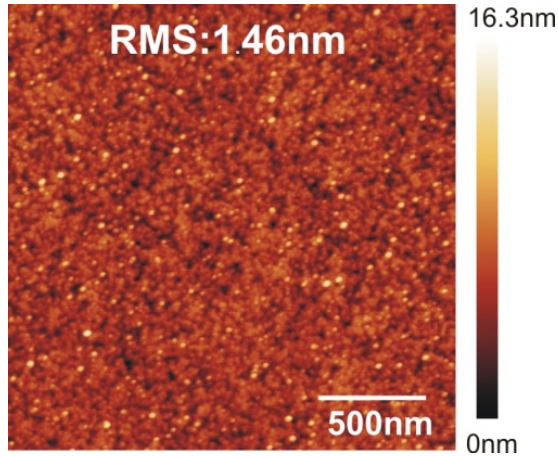


Cathodo-
luminescence

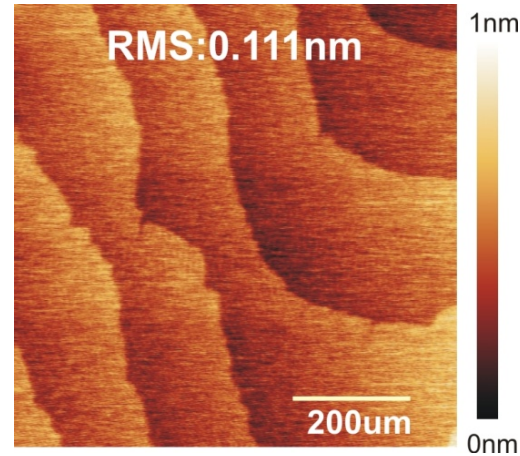
Dislocation density $\sim 1 \times 10^7 \text{ cm}^{-2}$

GaSb films on GaSb substrate

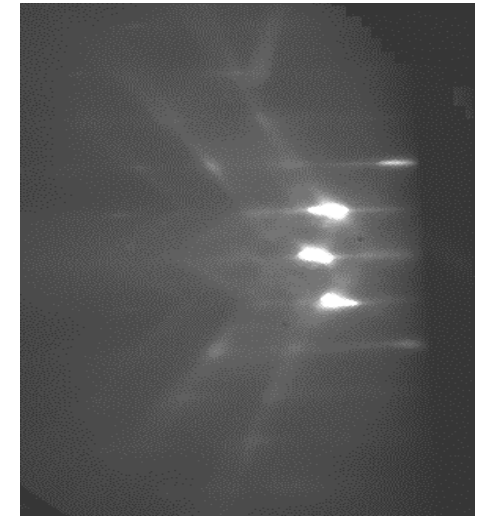
GaSb (100) homoepitaxial growth



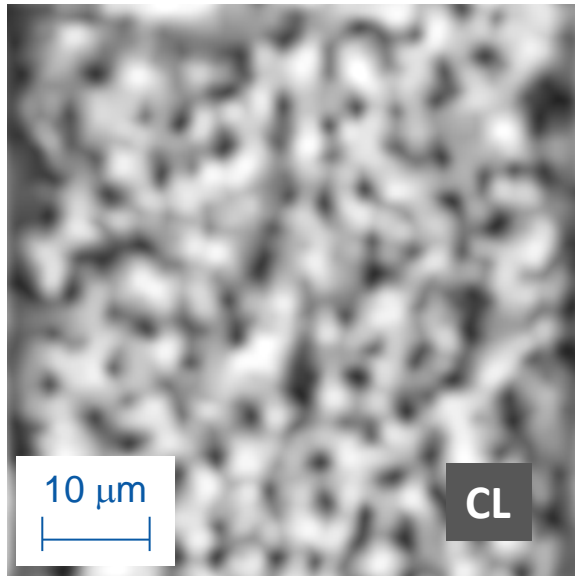
As-Received



GaSb film



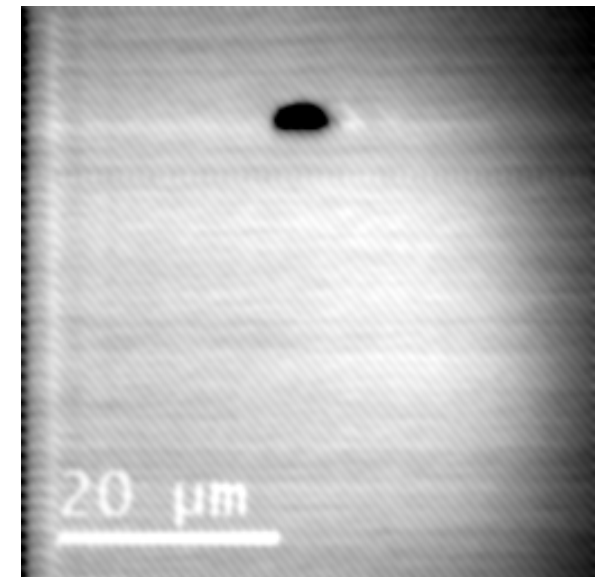
RHEED



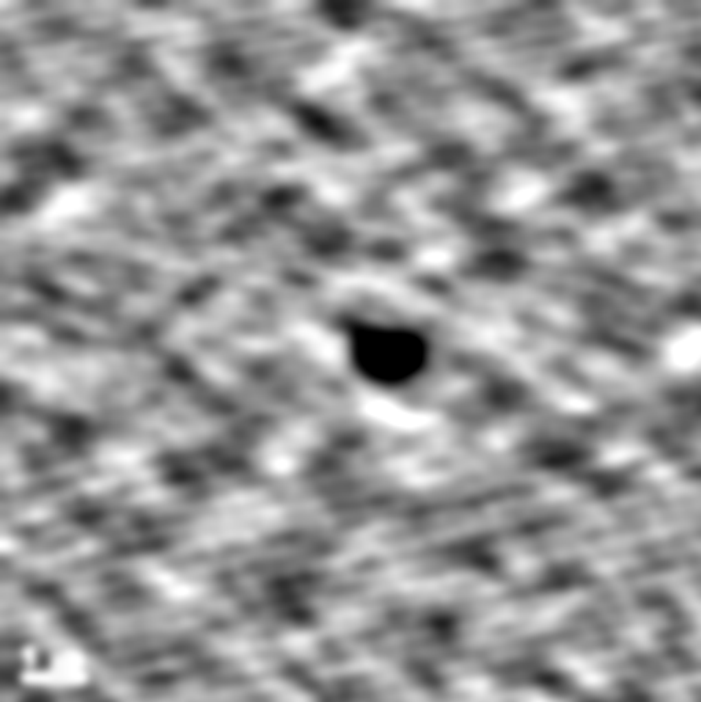
Bad surface prep

GaSb/GaSb
WaferTech (100) Sub

dislocation density
 $\sim 1 \times 10^5 \text{ cm}^{-2}$



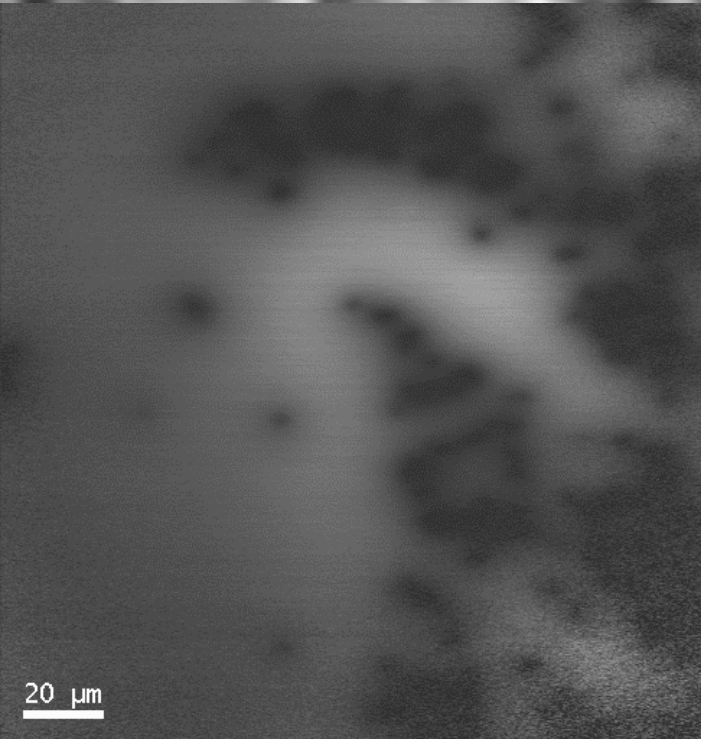
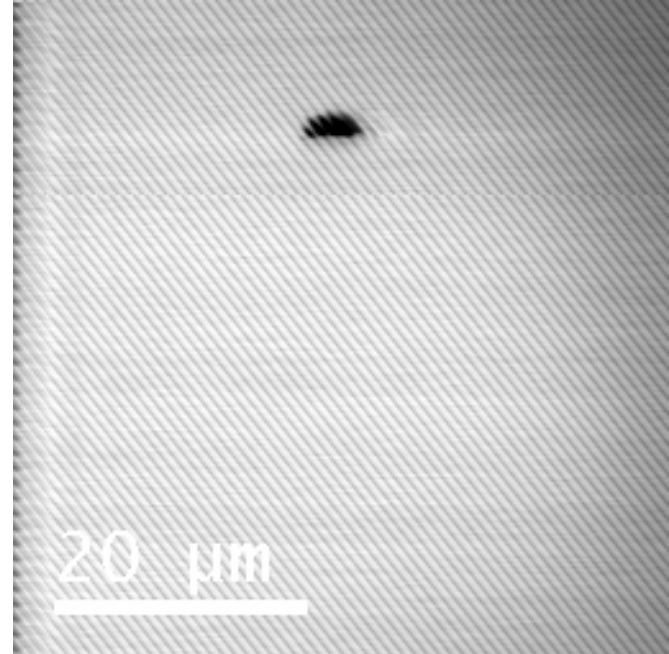
Good surface prep



InAs/GaAs



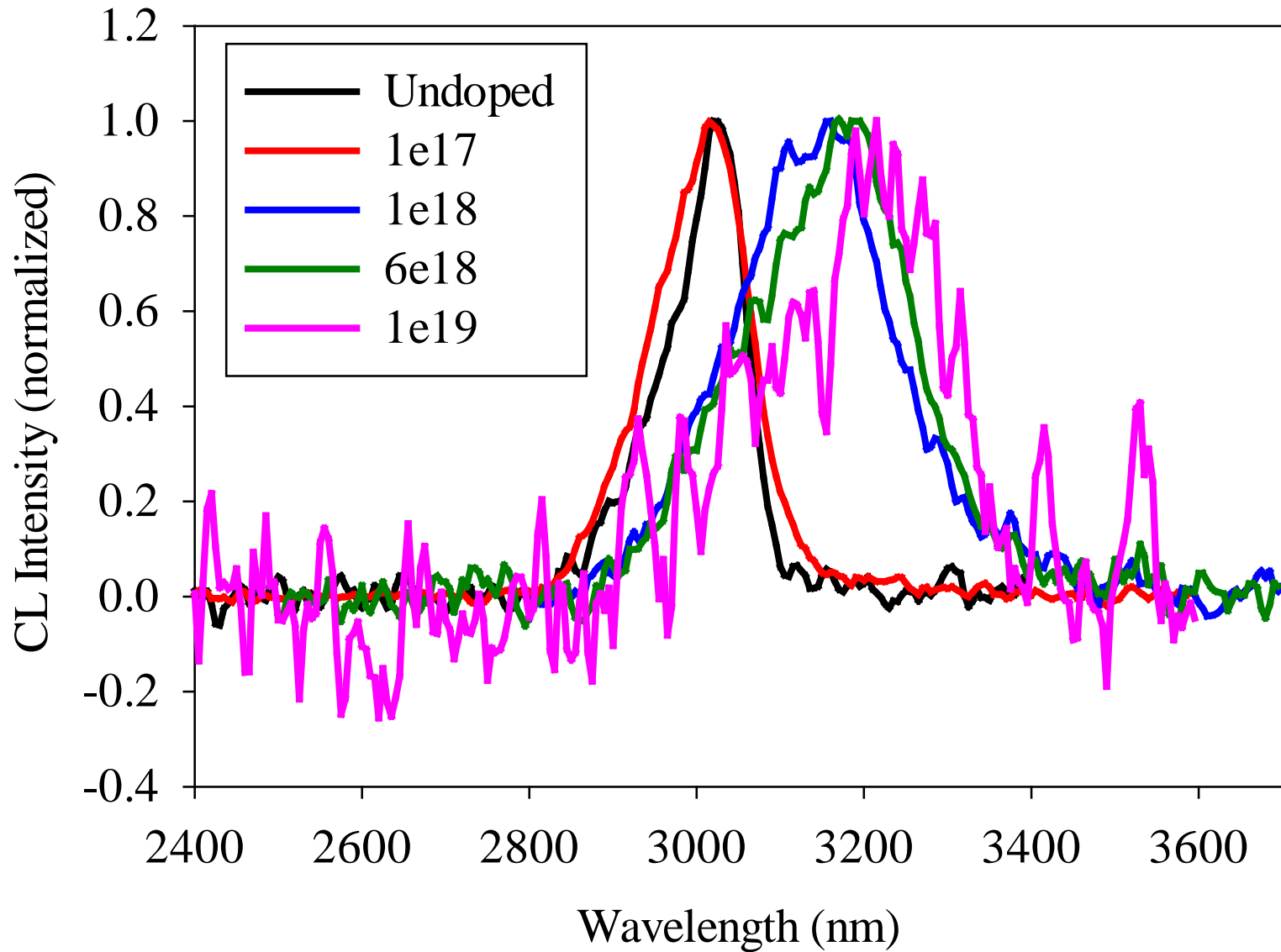
InAs/InAs

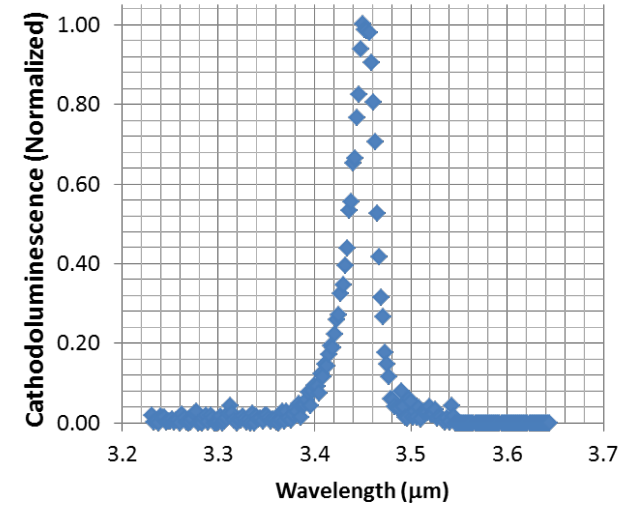
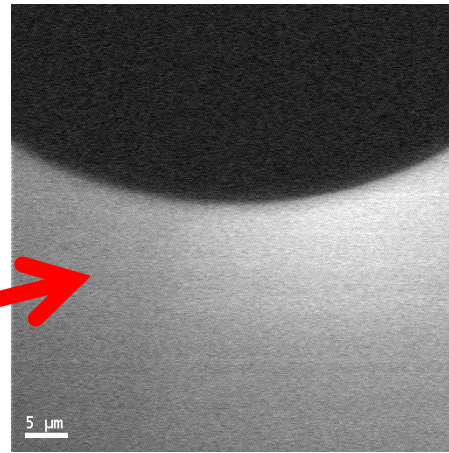
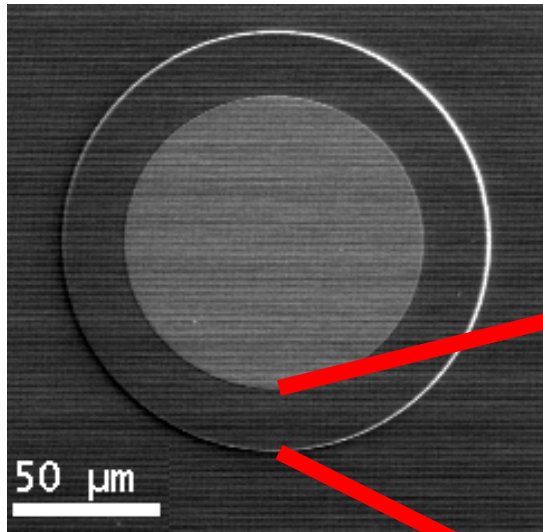


Defects in
InAs/GaSb SLS
(5 μm cutoff)

**Various MWIR
Images**

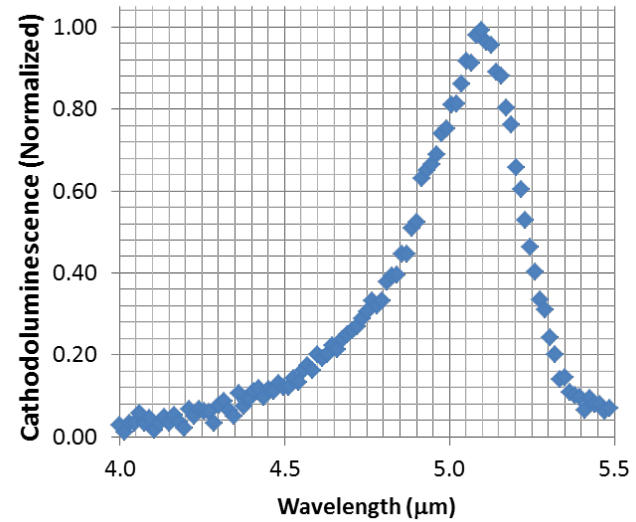
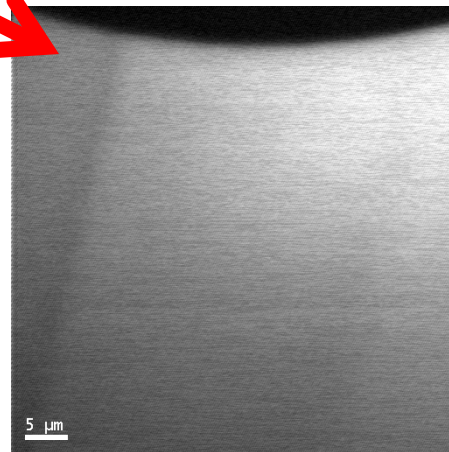
CL Spectra InAs Various doping levels (80K)





SEM (left) and CL
(right) of a mesa
diode structure

**Spectral CL of
InAs/GaSb SLS
Structure
(80K)**



Questions?